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2811

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Satya et al.

Attorney Docket No.: KLA1P016F/P642

Application No.: 09/648,095

Examiner: P. Cao

8

Filed: August 25, 2000

Group: 2811

Election
F JONES
7-30-02

Title: CHEMICAL MECHANICAL POLISHING
TEST STRUCTURES AND METHODS FOR
INSPECTING THE SAME

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the
United States Postal Service as First Class Mail to: Commissioner for
Patents, Washington, DC 20231 on July 12, 2002.

Signed: Natalie Morgan
Natalie Morgan

RESPONSE TO RESTRICTION REQUIREMENT B

Commissioner for Patents
Washington, DC 20231

Dear Sir:

In response to the Restriction Requirement dated 8 May 2002, Applicants hereby elect group A, claims 7 and 54-60, without traverse, to prosecute in the above-identified patent application.

If any fees are due in connection with the filing this Response to Restriction Requirement, the Commissioner is hereby authorized to charge such fees to Deposit Account 500388 (Order No. KLA1P016F).

Respectfully submitted,
BEYER WEAVER & THOMAS, LLP

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